L Number	Hits	Search Text	DB	Time stamp
•	2	((tr nch or via r op ning or gap or avity	USPAT;	2003/11/20
1		or re ess) sam (tungst n ad) sili ide)	US-P PUB;	15:50
		same (tungst n adj plug)).clm.	EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	5	((trench or via or opening or gap or cavity	USPAT;	2003/11/20
		or recess) same (tungsten adj silicide)	US-PGPUB;	15:51
		same (tungsten adj plug)).ti,ab,clm.	EPO; JPO;	
			DERWENT;	
1			IBM_TDB	
-	5	((trench or via or opening or gap or cavity	USPAT;	2003/11/20
		or recess) same (tungsten adj silicide adj	US-PGPUB;	15:51
		(layer or film)) same (tungsten adj	EPO; JPO;	
1		plug)).ti,ab,clm.	DERWENT;	
			IBM TDB	
-	5	((trench or via or opening or gap or cavity	USPAT:	2003/11/20
	-	or recess) same (tungsten adj (layer or	US-PGPUB;	15:52
		film)) same (tungsten adj silicide adj (layer	EPO; JPO;	
l		or film)) same (tungsten adj plug)).ti,ab,clm.	DERWENT;	
		or many, came (tangeten aaj prag), mjan, cam	IBM TDB	
_	5	((tungsten adj (layer or film)) same	USPAT;	2003/11/20
-	•	(tungsten adj silicide adj (layer or film))	US-PGPUB;	15:53
		same (tungsten adj plug)).ti,ab,clm.	EPO; JPO;	10.00
		same (tangaten auf plag)).tijasjemi.	DERWENT;	
			IBM_TDB	
_	7	((tungsten adj (layer or film)) same	USPAT;	2003/11/21
	•	(tungsten adj silicide adj (layer or film))	US-PGPUB;	10:12
		same (tungsten adj plug))	EPO; JPO;	10.12
		Jame (tangaton ad) piag//	DERWENT;	
ļ			IBM_TDB	1
	7	((tungsten adj (layer or film)) and (tungsten	USPAT;	2003/11/21
	•	adj silicide adj (layer or film)) and (tungsten	US-PGPUB;	09:20
Ì		adj plug)).clm.	EPO; JPO;	03.20
ļ		taj piag//tellili	DERWENT;	
			IBM_TDB	
	77	((tungsten adj (layer or film)) and (tungsten	USPAT:	2003/11/21
1	• •	adj silicide adj (layer or film))).clm.	US-PGPUB;	09:20
ļ		auj sinciae auj (layer or linii))).ciiii	EPO; JPO;	03.20
			DERWENT;	
			IBM_TDB	
_	33	((tungsten adj (layer or film)) near10	USPAT;	2003/11/21
-	33	(tungsten auj (layer or lilli)) hear lo	US-PGPUB;	09:22
		film))).clm.	1	VJ.ZZ
		,,,,	EPO; JPO; DERWENT;	
			1	
	5	//tungston adi /lavar av film\\ maau40	IBM_TDB	2002/44/24
-	ວ	((tungsten adj (layer or film)) near10	USPAT;	2003/11/21
]		(tungsten adj silicide adj (layer or film))	US-PGPUB;	09:23
		near10 plug)	EPO; JPO;	
	Į		DERWENT; IBM_TDB	

-	19	((tungsten adj (layer r film)) and (tungst n adj silicide adj (layer r film)) and plug). lm.	U PAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/11/21 09:25
-	33	(tungsten adj plug).clm. and (barrier adj layer) and (tungsten adj silicide)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/21 09:42
-	29	(tungsten adj plug).clm. and (barrier adj layer) and (tungsten adj silicide) and (tungsten adj (layer or film))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/21 09:43
•	15	(tungsten adj plug).clm. and (barrier adj layer) and (tungsten adj silicide adj (layer or film)) and (tungsten adj (layer or film))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/21 09:45
-	5	(tungsten adj plug).clm. and (barrier adj layer) and (tungsten adj silicide adj (layer or film)).clm. and (tungsten adj (layer or film)).clm.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/21 09:45